# Supporting information for "Hierarchical anti-reflective laser-induced periodic surface structures on amorphous Si films via ultrafast laser nanotexturing."

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#### 1 1. LIPSS periods predicted by Sipe and van Driel model.



Figure 1: Normal and anomalous LIPSS periods for Si of refractive index n = 3.69 (at  $\lambda = 1026$  nm) and with absorption  $n = 3.69 + i \times 0.1$  calculated for s- and p-polarized irradiation according to Sipe and van Driel model. Explicit formulae is given in [H. Iwase, et.al. Opt. Express 17,4388 (2009)]. The scattering efficacy factor calculated by the model correlates with surface LIPSS patterns. For the normal incidence s- and p-pol. are same and the two cases represents two possibilities for ripples (LIPSS) to be aligned to the polarisation of E-field (anomalous ripples) and perpendicular (normal) as schematically shown by thumbnail insets. The period of normal ripples is expected as  $\Lambda_n \approx \lambda/n$  and the anomalous  $\Lambda_a \approx \lambda$  at the peak efficacy factors, respectively.



Figure 2: AFM image of LIPSS morphology ( $E=1.5 \ \mu\text{J}, V=3 \ \mu\text{m/s}$ ) showing the maximal height of conical-shaped structures around 640 nm.

<sup>2</sup> 2. AFM analysis of LIPSS.



Figure 3: Diversity of the LIPSS morphologies is illustrated by series of top-view SEM images of LIPSS produced on 360-nm thick glass-supported a-Si film at variable pulse energies (1.45 - 1.85  $\mu$ J) and scanning speeds (1 - 100  $\mu$ m/s).

### 3. Variation of LIPSS morphology versus laser processing parameters.



Figure 4: (a-c) True-color SEM images of FIB cross-section cuts of LIPSS fabricated on the a-Si film surface at various scanning speeds V of 1  $\mu$ m/s (a), 3  $\mu$ m/s (b), and 50  $\mu$ m/s (c).)

5 4. True-color SEM contrast of FIB cross-section cut images.



Figure 5: (a-c) Comparative EDX spectra of pristine a-Si film (a), LIPSSs produced at V=100 (b) and 1  $\mu$ m/s (c) at  $E=1.5 \mu$ J. (d) Relative content of oxygen calculated from EDX spectra versus the scanning speed V for LIPSSs at  $E=1.5 \mu$ J. Relative content of oxygen obtained from EDX spectra of a-Si film ( $\approx 14 \%$ ) is provided as reference. Each dot is the average of at least 30 similar spectra.

#### 6 5. EDX analysis

Here, to confirm the increasing amount of oxygen in laser-processed areas 7 we analyzed their chemical composition with energy-dispersive X-ray spec-8 troscopy modality (Oxford Instruments, X-max) of the scanning electron 9 microscope (Carl Zeiss, Ultra55+). For all measurements, the acceleration 10 voltage and signal acquisition area was fixed at 20 kV and 50  $\mu m^2$ , respec-11 tively. Relative content of oxygen measured in the pristine a-Si film ( $\approx 14$ 12 %) was used as reference. Representative EDX spectra of pristine a-Si film 13 as well as LIPSS produced at printing speed of V=1 and 100  $\mu$ m/s are pro-14 vided in Fig. S3(a-c). Fig. S3(d) summarizes the relative content of oxygen 15 calculated from LIPSS produced at various scanning speed V. 16



Figure 6: Top-view SEM images of near-wavelength LIPSS formed on a-Si film at fixed pulse energy of 1.45  $\mu$ J and scanning speed of 3  $\mu$ m/s and different a-Si film thickness d: 60 nm, 108 nm, 180 nm and 300 nm. (Bottom) Dependence of LIPSS period on Si film thickness measured for surface morphologies produced at scanning speeds V=1, 5 and 10  $\mu$ m/s.)

#### 17 6. LIPSS period versus a-Si film thickness

To illustrate the step-like decrease of the near-wavelength period with a-Si 18 film thickness, we carried out series of experiments. The a-Si films of variable 19 thickness d ranging from 60 to 360 nm were deposited using magnetron sput-20 tering under identical conditions at constant evaporation speed. LIPSS were 21 fabricated under identical conditions at fixed pulse energy  $E=1.45 \ \mu J$  and 22 variable scanning speed V. Morphology of the produced LIPSS was further 23 analyzed with SEM imaging allowing to identify LIPSS period summarized 24 in Fig. S4(bottom) as a function of film thickness d. 25



Figure 7: Correlated SEM and Raman (@518±4 cm<sup>-1</sup>) images of the LIPSS surface produced on 180-nm thick a-Si film at  $V=3~\mu$ m/s and  $E=1.5~\mu$ J.)

# 7. Composition of LIPSS produced on the surface of 180-nm thick a-Si film.

In this section we show that LIPSS produced on the surface of twice thinner a-Si film (d=180 nm) preserve similar homogeneity and periodicity around 980 nm, while Raman mapping indicates similar structural and chemical composition - nc-Si pillars arranged parallel to the LIPSS orientation. This provide the way to tailor the height of the nc-Si pillars, which is obviously limited by the initial a-Si film thickness.



Figure 8: Optical photographs showing the deposition and spreading of the water droplets on a surface of pristine a-Si film (a), onto the 3D conical-shaped LIPSS at the center of patterned area (b), onto the boundary between similar LIPSS area and pristine a-Si film (c).)

## <sup>34</sup> 8. Wetting properties of LIPSS.

In this section, we highlight good wetting properties of LIPSS that facilitate analyte deposition in sensing experiments. Series of optical photographs

indicates that the contact angle for a nL-volume water droplet reduces from 37 38° for pristine as-Si film to almost zero for LIPSS showing their good super-38 hydrophilic properties (Fig. S7(a,b)). Upon its contact with the LIPSS, the 39 water droplet promptly spreads over the texture surface, and does not move 40 beyond its borders. Being deposited near the boundary between LIPSSs and 41 pristine a-Si (Fig. S7(c)), the capillary forces push the liquid towards the 42 textured surface (even the part situated on the smooth a-Si), where the liq-43 uid finally evaporates providing analyte pre-concentration. Noteworthy, the 44 left-side LIPSSs boundary is not shown owing to limited field of view of the 45 optical system that was shifted to the right to show the liquid behavior on 46 the right-side boundary. 47



Figure 9: Schematic of the experimental setup used to assess applicability of LIPSS as SEF-based sensor of  $[{\rm Au}^{3+}]$  ions.

<sup>48</sup> 9. Experimental setup for SEF sensing experiments.



Figure 10: Difference of visible-range transmission through the 3D conical-shaped LIPSS  $(V=3 \ \mu m/s, E=1.5 \ \mu J)$  for white light polarized either parallel (green) or perpendicular (red) to the LIPSS orientation. Top insets schematically illustrate excitation conditions as well as provide reference top-view SEM image of the tested LIPSS.)

#### <sup>49</sup> 10. Polarization-resolved transmission of 3D conical-shaped LIPSS.

Laser sources generating linearly polarized radiation are typically used 50 for sensing experiments. In our sensing experiments shown in this paper, 51 LIPSS morphologies represent periodical arrangement of nc-Si pillars capped 52 with  $3D SiO_2$  protrusions were used. As any type of the grating, our textures 53 are expected to have anisotropy of the optical properties, which means that 54 the polarization direction of the pump laser radiation in sensing experiments 55 should be properly adjusted to ensure maximal performance. To illustrate 56 this feature, here we measure visible-range FTIR transmission thought the 57 LIPSS (similar to those used for sensing experiments) probed with broad-58 band visible light radiation polarized either parallel (green) or perpendicular 59 (red) to the LIPSS orientation (Fig. S5). These measurements showed de-60 creased transmission for light polarized perpendicular to nc-Si pillars orienta-61 tion. Noteworthy, the reflection coefficient for both polarization orientations 62 remained almost the same. Unfortunately, experimental limitations of the 63 optical setup do not allow us to probe in a similar way near-IR part of the 64 spectrum, where the anisotropy of optical properties is expected to be pro-65 moted by the LIPSS periodicity, which will be the subject of our further 66 studies. 67